EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L2	5	US-1750442-\$.DID. OR US-1750383-\$. DID. OR US- 1234567-\$.DID. OR JP-1234567-\$.DID. OR JP-2003344608-\$. DID. OR JP- 2002776680-\$.DID.	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2008/07/01 11:03
L3	30	US-1713794-\$.DID. OR US-1234567-\$. DID. OR US-6258347-\$.DID. OR US-6303675-\$.DID. OR US-6369155-\$. DID. OR US-20010012565-\$.DID. OR US-20030076596-\$.DID. OR JP-1234567-\$.DID. OR JP-6140845-\$.DID. OR JP-6140845-\$.DID. OR JP-9208898-\$.DID. OR JP-10330619-\$.DID. OR JP-2000248183-\$. DID. OR JP-2000352620-\$.DID. OR JP-20012923-\$. DID. OR JP-20012923-\$. DID. OR JP-200137007-\$. DID. OR JP-2001235604-\$. DID. OR JP-2001235604-\$. DID. OR JP-2001235604-\$. DID. OR JP-2001235604-\$. DID. OR JP-200236452-\$. DID. OR JP-200236452-\$. DID. OR JP-2002265866-\$.DID. OR JP-2003205581-\$. DID. OR JP-2003344608-\$.DID.	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2008/07/01 11:04

S1	31521	(curing resin or cured resin or cure resin)	US-PGPUB; USPAT	ADJ	ON	2008/06/24 13:50
S2	17	(siloxane oligomer with ethylene glycol)	US-PGPUB; USPAT	ADJ	ON	2008/06/24 13:52
S3	4	S1 and S2	US-PGPUB; USPAT	ADJ	ON	2008/06/24 13:52
S4	1240	S1 and (anti\$1reflect \$ or anti reflect\$) and film	US-PGPUB; USPAT	ADJ	ON	2008/06/24 13:54
S 6	5	US-1750442-\$.DID. OR US-1750383-\$. DID. OR US- 1234567-\$.DID. OR JP-1234567-\$.DID. OR JP-2003344608-\$. DID. OR JP- 2002776680-\$.DID.	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2008/06/24 14:11
S7	30	US-1713794-\$.DID. OR US-1234567-\$. DID. OR US- 6258347-\$.DID. OR US-6303675-\$.DID. OR US-6369155-\$. DID. OR US- 20010012565-\$.DID. OR US-20030076596- \$.DID. OR JP- 1234567-\$.DID. OR JP-6140845-\$.DID. OR EP-0776925-\$. DID. OR JP- 10330619-\$.DID. OR JP-2000248183-\$. DID. OR JP- 2000352620-\$.DID. OR JP-20012923-\$. DID. OR JP- 200191705-\$.DID. OR WO-0137007-\$. DID. OR JP- 2001194505-\$.DID. OR JP-2001235604-\$. DID. OR JP- 2001343529-\$.DID. OR JP-200236452-\$. DID. OR JP- 200277680-\$.DID. OR JP-2002235036-\$. DID. OR JP- 2002265866-\$.DID.	US-PGPUB; USPAT; EPO; JPO; DERWENT	ADJ	ON	2008/06/24 14:13

		OR JP-2003205581-\$. DID. OR JP- 2003344608-\$.DID.				
S64	1983	cur\$3 and (Si or silicon) and (F or fluorine) and (spectroscop\$ or x \$1ray or x ray or photoelectron spectroscopic) and peak intensity	US-PGPUB; USPAT	ADJ	ON	2008/06/25 14:56
S65	344644	"528"/\$.ccls. or "428"/\$.ccls. or "359"/\$.ccls.	US-PGPUB; USPAT	ADJ	ON	2008/06/25 14:57
S66	272	S64 and S65	US-PGPUB; USPAT	ADJ	ON	2008/06/25 14:58
S67	25	S66 and (anti \$1reflect\$3 or anti reflect\$3)	US-PGPUB; USPAT	ADJ	ON	2008/06/25 14:58
S68	532	(cured or curing) and (Si or silicon) and (F or fluorine) and (spectroscop\$ or x\$1ray or x ray or photoelectron spectroscopic) and peak intensity	US-PGPUB; USPAT	ADJ	ON	2008/06/25 15:03
S 69	23	\$68 and (anti \$1reflect\$3 or anti reflect\$3)	US-PGPUB; USPAT	ADJ	ON	2008/06/25 15:03
S70	615	(anti reflection or anti \$1reflection) and peak intensity	US-PGPUB; USPAT	ADJ	ON	2008/06/25 15:34
S71	18	(anti reflection or anti \$1reflection) same peak intensity	US-PGPUB; USPAT	ADJ	ON	2008/06/25 15:34
S72	19	(x ray photoelectron spectroscopic or x \$1ray photoelectron spectroscopic) and peak intensity	US-PGPUB; USPAT	ADJ	ON	2008/06/25 16:06
S73	18	(anti reflection or anti \$1reflection) same peak intensity	US-PGPUB; USPAT	ADJ	ON	2008/06/25 16:15
S77	581	S76 and (anti \$1reflect\$ or anti reflect\$) and film	US-PGPUB; USPAT	ADJ	ON	2008/06/26 10:44
S78	17	(siloxane oligomer with ethylene glycol)	US-PGPUB; USPAT	ADJ	ON	2008/06/26 10:44

S79	14	S78 and (cured or curing)	US-PGPUB; USPAT	ADJ	ON	2008/06/26 10:44
S92	28	(siloxane oligomer with ethylene glycol)	US-PGPUB; USPAT; USOCR; FPRS; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2008/06/26 11:02
S104	513	(siloxane oligomer or silicone oligomer) and (ethylene glycol)	US-PGPUB; USPAT	ADJ	ON	2008/06/30 07:56

7/ 1/ 2008 11:08:55 AM

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